

# **Enhanced Fluoride over-coated Al Mirrors for FUV Astronomy**

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### ABSTRACT

stronomical observations in the Far Ultraviolet (FUV) spectral region are some of the more challenging due to the very distant and faint objects that are typically searched for in cosmic origin studies such as origin of large scale structure, the formation, evolution, and age of galaxies and the origin of stellar and planetary systems. These challenges are driving the need to improve the performance of optical coatings over a wide spectral range that would increase reflectance in mirrors and reduced absorption in dielectric filters used in optical telescope for FUV observations. This paper will present recent advances in eflectance performance for AI+MgF2 mirrors optimized for Lyman-alpha wavelength by performing the deposition of the MgF2 overcoat at elevated substrate temperatures. We will also present optical characterization of little studied rare-earth fluorides such as GdF3 and LuF3 that exhibit low-absorption over a wide wavelength range and could therefore be used as high refractive index alternatives for ielectric coatings at FUV wavelengths.

### **Description and Objectives:**

- 1. To develop on a large scale (up to 1 meter diameter) coating of mirrors using a Al+MgF2 coating process to enhance performance in the Far-Ultraviolet (FUV) spectral range
- 2. Study other dielectric fluoride coatings and other deposition technologies such as Ion Beam Sputtering (IBS) that is known to produce the nearest to ideal morphology optical thin film coatings and
- 3. Optimize deposition process of lanthinide trifluorides as high-index materials that when paired with either MgF2 or LiF will enhance reflectance of Al mirrors at Lyman-alpha

### Approach for Objective 1:

Retrofit a 2 meter coating chamber with heaters/thermal shroud to perform coating iterations at a high deposition temperatures (200-300°C) to further improve performance of protected Al mirrors with either  ${\rm MgF}_2$  or LiF overcoats

### Tasks Description:

- Design and fabrication of internal heat shields for GSFC 2-meter Chamber.
- These wall panels were made out of stainles steel and were designed to easily interface with the existing internal configuration of Optimized coating parameter for high FUV
- reflectance of a distribution of slides in center and out to a ~0.5 meter radius.







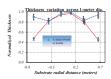




- The Images above show the fully assembled internal heat shields, power supply and quartz halogen lamps
- The images above some use may assume mental next sineus, power supply and quart. Langen ample Heater were first tested on 08/13/13 and found maximum temperature reached was only 100 °C after 5 hi Doubled lamp power output from 500 W to 1000 W each (4000 W total) Additional testing yielded a maximum temperature of 130 °C
- Further testing does after wrapping best shield paneds with aluminum foll provide for a much quicker raise in temperature, reaching 220 °C in less than 1 hour (see graph below on the right)

  Performed a coating run with small 2x2in substrates located at various radius inside chamber (see graph below on the left)





# **Approach for Objective 2:**

Upgrade existing Ion Beam Sputtering (IBS) chamber with a two-gas flow controller system. Krypton gas is used during IBS deposition. In addition, Freon (CF4) is used as reactive gas to replenish the targets (MgF2) stoichiometry. Finally, we added heaters to the chamber to improve microcrystalline film properties.



# ctive Ion Beam Sputtering (RIBS)

- Keactive for Death Sputtering (Lease)

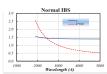
  Non-thermal evaporation process

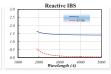
  Atoms from a target are ejected by momentum transfer from energetic atom-size particles

  Particles are energized by an ion gun

  Deposition rate are much lower than PVD 1-5 Å/Sec.

on and characterization of MgF2 films using the IBS process did not give satisfactory results (see graphs bel





### **Approach for Objective 3:**

Optimize deposition process of lanthinide trifluorides as high-index materials that when paired with either  $\mathrm{MgF}_2$  or LiF will enhance reflectance of Al mirrors at Lyman-alpha

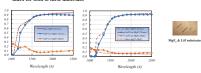
### Tasks Description for FUV Dielectric Coatings:

- Choose a high-index (H) and low-index (L) pair combination
- Form a pair of (H,L) layers with thicknesses equal to a Quarter-Wave Optical thickness at the design wavelength.
- Repeat the stack above until desired reflectance is achieved

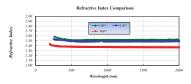


Options for FUV coating candidates: Low Index:  $MgF_2$  (n~1.38) High Index:  $LuF_3$ ,  $GdF_3$ 

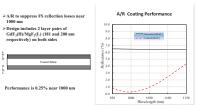
The two graphs below show transmission and reflectance of  $GdF_3$  (right) and  $LuF_3$  (left) films grown on  $MgF_2$  substrates. These data are used to extract refractive index for both of these materials.



The data on the graphs shown above were used to obtain refractive index (n and k) for MgF<sub>2</sub>, GdF<sub>3</sub>, and LuF<sub>3</sub> films. The results are shown in graph



# Example of A/R coating design and fabrication:



# Spectral Characterization:

Spectrometer used to collect spectral scan of transmission and/or reflectance from 90 nm to 2500 nm are two gratings instrument shown below



# PE Specifications

\*Double-beam ratio recording grating monochromator \*Wavelength range: 180-3300 nm; Resolution: .05-5 nm \*Quartz Tungsten Halogen and D2 lamps \*Lead-sulfite and PMT detectors •Photometric Range: Up to ±8 Absorbance units (with

\*Universal Reflectance Accessory for normalized reflectance between 8° and 68° angle of incidence

# •ACTON Specifications

ngth range from 30 nm to 325 nm Windowless hydrogen-purged light source (disemission lines between 90 nm and 160 nm and a continuum at higher  $\lambda$ 

continuum at higher A

-Photomultiplier Cathode Tube with light -pipe equ
with a fluorescence coating (sodium salicyilate) for
converting FUV to visible light

Sample compartment allows absolute transmission reflectance measurements at varying angles of inci (12-68°) without the need of a reference

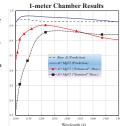
# Al+MgF<sub>2</sub> Coating Performance:

### 3-step coating process:

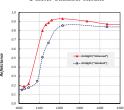
- Al is coated on the substrate at room temperature to the planned layer thickness As soon as possible after the Al deposition, overcoat the Al layer and substrate at room temperature with a thin 4-5 nm layer of  $MgF_2$  in order to protect the Al from oxidation
- and contamination. > Heat the substrate to 200-300  $^{\circ}\text{C}$  and finish the planned final MgF $_2$  thickness MgF2.

### **Results:**

- Predicted vs. measured reflectance of bare Al and Al+MgF<sub>2</sub> reflectance (Al: 50.0 nm; MgF2: 25.0nm)
- Enhanced performance is obtained by heating (~220 °C) substrate during MgF2 deposition
- ➤ Reflectance is > 80% even at 115.0 nm



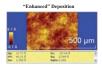
### 2-meter Chamber Results



- > Recently started test run in center of 2-meter chambers to optimize the 3-step process for depositing Al+MgF<sub>2</sub> coatings
- Graph on left display reflectance data taken of test coupons done in this chamber.
- "Standard" test sample was prepared under normal conditions on 08/22/2013
- "Enhanced" was produced with a "hot" (220°C MgF<sub>2</sub> deposition done on 11/27/2103.
- > These data represent an important mileston

### Micro-roughness Al+MgF2 Films







The tables above show micro-roughness results on two classes of Al+MgF, coatings done with the MgF<sub>2</sub> layer deposited at ambient (left) and at elevated (right) temperatures. The table on the right shows the average roughness for the elevated MgF<sub>2</sub> depositions is 30% smaller.

## **Conclusions**

- Reported gains in FUV reflectivity of Al+MgF2 and Al+LiF mirrors by employing a 3-step process during PVD coating deposition of these materials.
- Successfully demonstrated gains in FUV reflectance using a large 2-meter chamber that will allow coating up to 1 meter diameter optics.
- Characterization of lanthanide tri-fluoride material candidates to determine their FUV transparency for development of dielectric coatings
- Will plan to refurbish a second 1-meter chamber to perform IBS film deposition of MgF2/LiF materials.